

8-4-09

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EV372459219



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 10/625,952
Filing Date July 2, 2004
Inventor Ying Huang et al.
Assignee Micron Technology, Inc.
Group Art Unit 2815
Examiner J.H. Nguyen
Attorney's Docket No. MI22-2347
Customer No. 021567

Title: An Improved Method, Structure and Process Flow to Reduce Line-Line Capacitance with Low-K Material

RESPONSE TO JULY 2, 2004 OFFICE ACTION

To: Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

From: D. Brent Kenady
Tel. 509-624-4276; Fax 509-838-3424
Wells St. John P.S.
601 W. First Avenue, Suite 1300
Spokane, WA 99201-3817

Sir:

Responsive to the Office Action dated July 2, 2004, Applicant amends and remarks as follows:

AMENDMENTS

Underlines indicate insertions and ~~strikeouts~~ indicate deletions.